PATENT SPECIFICATION

1 543 266 (11)

(21) Application No. 32957/76

(22) Filed 6 Aug. 1976

(31) Convention Application No. 50/096155 (32) Filed 7 Aug. 1975 in

(33) Japan (JP)

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(52) Index at Acceptance 20X 211 212 234 25X 27Y 301 309 372 380 C19E2A C19E2B C19JX C19JY C19Y



(54) THERMALLY DEVELOPABLE LÍGHT-SENSITIVE MATERIALS

ERRATA

SPECIFICATION NO 1543266

Page 5, line 7, after containing delete 1i insert 10

Page 7, line 21, delete calcium, strontium, (second occurrence)

Page 7, line 22, delete barium, zinc, cadmium, mercury, aluminum,

Page 12, line 19, for acryl read acyl

Page 13, line 9, for 2, r, 5 read 2, 4, 5

Page 13, line 35, for di-5-read di-t-

Page 15, line 102, for rreducing read reducing

Page 16, line 37, for 54428176 read 54428/76

Page 16, line 57, for precent read prevent

Page 20, line 29, for loaw read low

Transpose pages 23 and 24

THE PATENT OFFICE 29 May 1979

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is an important object to find compound of low toxicity which can serve as a substitute for a mercury compound.

It is, therefore, one object of the present invention to provide a thermally developable light sensitive material having an improved green shelf life.

Another object of the present invention is to provide a thermally developable light- 40 sensitive material having improved whiteness.

A further object of the present invention is to provide a thermally developable lightsensitive material wherein increased thermal fog (corresponding to the fog produced in the background on thermal development) attributable to storage prior to development is suppressed.

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(54) THERMALLY DEVELOPABLE LIGHT-SENSITIVE MATERIALS

We, FUJI PHOTO FILM CO., LTD., a Japanese Company, of No. 210, Nakanuma, Minami/Ashigara-Shi, Kanagawa, Japan, do hereby declare the invention for which we pray that a patent may be granted to us, and the method by which it is to be performed, to be particularly described in and by the following statement:-

The present invention relates to thermally developable light-sensitive materials. Thermally developable light-sensitive materials utilizing a composition containing as essential components an organic silver salt, a small amount of silver halide and a reducing agent are disclosed in U.S. Patents Nos. 3,152,904 and 3,457,075. In these light-sensitive systems, silver halides remain in the light sensitive material after development and change in color upon light-exposure, i.e., they are not stabilized to light. Nevertheless, these systems produce satisfactory results, as well as the other system wherein residual silver halide receives a stabilizing treatment to light. This is because only a small amount of silver halide

is used and a large portion of the silver component is present in the form of white or pale yellow organic silver salts which are stable to light so that they hardly blacken upon lightexposure. Thus, even if coloration results from the decomposition of residual silver halide caused by light-exposure, such slight coloration can hardly be perceived by the eye. In the above-described light sensitive systems, images are formed by the following mechanism: the oxidizing agent (organic silver salts) and the reducing agent incorporated in the light sensitive layer undergo a redox reaction in the presence of a catalytic amount of exposed silver halide when the system is heated to 80°C, preferably up to 100°C, after the completion of

image-wise exposure, although the system is inert at ordinary temperature, resulting in the liberation of silver which causes a quick blackening in exposed areas of the light sensitive layer to produce contrast to unexposed areas (background). In addition, thermally developable light sensitive materials of this kind include those

which contain as a photocatalyst a light sensitive complex prepared from silver and a dye instead of the aforesaid silver halide, as disclosed in Japanese Applications (Laid-Open) 4728/71 and 28221/73, and Japanese Patent Publication 25498/74; and those which contain as organic silver salts a high sensitivity organic silver salt and a low sensitivity organic silver salt in combination, and, therefore, can be free of silver halide, as disclosed in Japanese Applications (Laid-Open) 8522/75. Accordingly, these thermally developable light sensitive materials are within those to which the technique of the present invention is applicable

The addition of mercury compounds to thermally developable light sensitive materials improves the green shelf life thereof as disclosed in U.S. Patent 3,589,903. However, mercury compounds are undesirable because they are, in general, highly toxic. Therefore, it is an important object to find compound of low toxicity which can serve as a substitute for a mercury compound.

It is, therefore, one object of the present invention to provide a thermally developable light sensitive material having an improved green shelf life.

Another object of the present invention is to provide a thermally developable lightsensitive material having improved whiteness.

A further object of the present invention is to provide a thermally developable lightsensitive material wherein increased thermal fog (corresponding to the fog produced in the background on thermal development) attributable to storage prior to development is suppressed.

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Still another object of the present invention is to provide a thermally developable lightsensitive material which produces, on image-formation after prolonged storage, an image exhibiting a color tone equal to that of an image obtained just after the production of the light sensitive material.

Another object of the present invention is to provide a thermally developable lightsensitive material wherein coloring of the background of the image obtained upon exposure

to light (termed color change caused by light hereinafter) is reduced.

A further object of the present invention is to provide a thermally developable light

sensitive material which exhibits high sensitivity.

We have found that these objects can be attained with a heat-developable light-sensitive material containing one or more trivalent and/or one or more tetravalent cerium com-

pounds.

A thermally developable light-sensitive material of the present invention comprises: (a) an organic silver salt; (b) a photocatalyst which catalyses the reaction of an organic silver salt with a reducing agent to form a silver image; (c) a reducing agent selected from substituted phenols; optionally substituted bis, tris and tetrakisphenols; 3-pyrazolidones, pyrazolines and pyrazolones; phenylenediamines; hydroxyamines; hydroxaminic acids; hydrazides; indane-1, 3-diones, amidoximes, substituted hydropyridines, organic hydrazone compounds, hydrazines, amino-9, 10-dihyroacridines, 1,4-dihydropyridines, acetoacetonitriles, p-oxyphenylglycine, 4,4'-diaminodiphenyl, 4,4'-dimethylaminodiphenyl and 4,4',4"-diethylamino triphenylmethane in a support and/or in one or more layers provided on the support, and, further, (d) at least one cerium compound selected from trivalent and tetravalent cerium compounds can be used, if desired). The term "substituted phenols" does not include substituted naphthalenes or naphthols.

Component (d) which is the most characteristic component in the present invention comprises one or more trivalent and/or one or more tetravalent cerium compounds. Tetravalent cerium compounds remarkably improve green shelf life. In contrast, trivalent cerium

compounds remarkably improve whiteness.

Preferred examples of trivalent or tetravalent cerium compounds include compounds represented by the following general formulae (I) and (II):

 $Ce_1Xm \cdot xH_2O \qquad (1)$ $M_nCe_pX_q \cdot yH_2O \qquad (II)$

wherein Ce represents a trivalent or a tetravalent cerium atom; X represents an anion, specific examples of which include a nitrate ion, a hydroxide ion, a nitro ion, a sulfate ion, an oxygen ion, a titanate ion, an acetate ion, an acetyl acetonate ion, a carbonate ion, a halogen ion (e.g., chlorine, bromine and iodine atoms), long chain aliphatic carboxylic groups (most preferably having 10 to 30 carbon atoms, e.g., laurate, palmitate, stearate and behenate groups), a perchlorate ion and a phosphorate ion. Particularly preferred examples are a nitro ion, halogen ions and long chain aliphatic carboxylic groups; M represents a cation, specific examples of which include a hydrogen ion, an alkali metal ion (e.g., lithium, sodium, potassium, cesium and rubidium atoms), onium groups (e.g., ammonium groups, phosphonium groups, arsonium groups, stibonium groups, sulfonium groups, selenonium groups, iodonium groups (of the above, R₂N groups are preferred, the above, R₂N groups are preferred, the above the state of the above that are preferred to the above the state of the above that are preferred to the above the state of the above the wherein R represents H, an alkyl group having 1 to 22 carbon atoms, an aryl group having 6 to 22 carbon atoms, e.g., an NH₁ group, a tetramethyl-ammonium group)); l, m, n, p and q represent integers necessary to render the compound neutral, for example, l is equal to 1 and m is equal to 4 when Ce is a tetravalent cerium atom, n is equal to 2, p is equal to 1 and q is equal to 6 when Ce is a tetravalent cerium atom, M is a monovalent cation and X is a 50 monovalent anion, and I is equal to 2 and m is equal to 3 when Ce is a trivalent cerium atom and X is a divalent anion; and x and y each represents an integer (including zero; most preferably 0 to 16) which cannot be unequivocally defined because they depend upon the conditions of manufacture and storage (x and y, however, generally are such as give a high degree of deliquescence; there are many commercial hydrates of this kind represented by

crystallization degrees can be used, if desired.

Specific examples of trivalent and tetravalent compounds are given below:
Ce(OH)₃, Ce(OH)₄, CeO₂, Ce₂O₃, Li₈CeO₆, Na₂CeO₃, KCeO₂, K₂CeO₃, CeN, Ce(NO₃)₃, Ce(NO₃)₃·6H₂O, Ce(NO₃)₃·5H₂O, Ce(NO₃)₃·4H₂O, Ce(NO₃)₄·5H₂O, CeOH (NO₃)₃·4H₂O, Ce(NO₃)₄·5H₂O, CeOH (NO₃)₃·4H₂O, CeOH (

the notation xH2O). In the present invention, a mixture of compounds having varying water

60 xH₂O₁ (x = 0 and/or 3), KCe(NO₃)₄·H₂O₁ K₂Ce(NO₃)₅, K₂Ce(NO₃)₆, RbCe(NO₃)₄·H₂O₁, Rb₂Ce(NO₃)₅·4H₂O₁ Rb₂Ce(NO₃)₆, CsCe(NO₃)₅·H₂O₁ (NH₂)₂Ce(NO₃)₆,

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the thione compounds are represented by the following general formula

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wherein R represents the atomic group necessary to complete a 5-membered heterocyclic ring, such as a thiazoline ring, imidazoline ring, pyrazoline ring, etc., and Z represents an alkylene group containing 1 to 10 carbon atoms.); silver S-2-amino- phenylthiosulfate as disclosed in U.S. Patent 3,549,379; 2-mercaptobenzoxazole silver, mercaptoxadiazole silver, 2-mercaptobenzothiazole silver, 2-mercaptobenzothiazole silver, 3-mercapto-4- phenyl-1,2,4-triazole silver, silver salts of mercaptotriazines, silver salts of 2-mercapto-5- aminothiadiazoles, silver salts of 1-phenyl-5- mercaptotetrazoles, silver salts of dithiocarbonates such as a silver salt of dithioacetate, thioamide silver, silver salts of thiopyridines such as 5-carbethoxy-1-methyl-2- phenyl-4-thiopyridine silver, dithiodi- hydroxybenzole silver, silver diethyl-dithio carbamates.

(3) Carboxy group-containing organic silver salts: (a) Silver salts of aliphatic carboxylic acids; silver caprate, silver laurate, silver myristate, silver palmitate, silver stearate, silver behenate, silver maleate, silver fumarate, silver tartarate, silver furoinate, silver linolate, silver oleate, silver hydroxystearate, silver adipate, silver sebacate, silver succinae, silver archidonate, silver erucinate, silver oxalate, silver undecylenate, silver lignocerate, silver salts of thioether group containing aliphatic carboxylic acids as disclosed in, for example, U.S. Patent 3,330,663; silver propionate, silver valerate, silver caproate, silver azalainate rebutylhydroperoxide, silver malonate, silver glutarate, silver propelate, silver azalainate

Patent 3,330,663; silver propionate, silver valerate, silver caproate, silver caprylate, silver t-butylhydroperoxide, silver malonate, silver glutarate, silver pimelate, silver azelainate, silver chloroacetate, silver trichloroacetate, silver fluoroacetate, silver iodoacetate, silver sarcosinate, silver aniline acetate, silver mandelate, silver hippurate, silver naphthalene acetate, silver creatinate, silver lactate, silver α- or β-mercapto propionate, silver levulinate, silver salts of amino acids such as L-alanine, γ-amino lactic acid, ε-aminocapronic acid, L-aspartic acid, L-glutamic acid, L-leucine, etc., silver tricarballylate, silver nitrilotriacetate, silver citrate, silver ethylenediamine tetraacetate, silver acrylate, silver methacrylate, silver crotonate, silver sorbinate, silver itaconate. (b) Silver salts of aromatic carboxylic acids; silver benzoate, silver η-methylbenzoate, silver σ-methylbenzoate, silver methylbenzoate, silver σ-methylbenzoate, silver σ-methylbenzoate, silver σ-methylbenzoate, silver

m-methylbenzoate, silver p-methylbenzoate, silver 2,4-dichloro- benzoate, silver acetamidobenzoate, silver p-phenylbenzoate, silver gallate, silver tannate, silver phthalate, silver terephthalate, silver salicylate, silver phenyl acetate, silver pyromellitate, silver salt of 4'-n-octadecyloxy diphenyl-4- carboxylic acid, silver m-nitrobenzoate, silver o-aminobenzoate, silver furoinate, silver p-hexoxybenzoate, silver octadecoxy- benzoate, silver cinnamate, silver p-methoxycinnamate, silver furoate, silver p-nitrophenyl acetate, silver nicotinate, silver isonicotinate, silver picolinate, silver pyridine-2,3- dicarbonate.

(4) Silver sulfonates: silver sulfonate, silver 1-propane sulfonate, silver 1-butane sulfonate, silver 1-pentane sulfonate, silver 1-pentane sulfonate, silver allyl sulfonate, silver benzene sulfonate, silver 1-n-butylnaphthalene- 4-sulfonate, silver naphthalene-1,5- disulfonate, silver α - or β -naphthalene sulfonate, silver p-toluene sulfonate, silver toluene-3,4- disulfonate, silver diphenylamine sulfonate, silver 2-naphthol- 3,6-disulfonate, silver anthraquinone- β - sulfonate, silver 2-amino-8-naphthol- 6-sulfonate, silver p-styrene sulfonate.

(5) Silver sulfinates:
silver p-toluene sulfinate, silver p-acetoaminobenzene sulfinate, silver benzene sulfinate.
(6) Silver organic phosphates:

silver phenyl phosphate, silver p-nitrophenyl phosphate, silver β -glycerophosphate, silver 1-naphthyl phosphate, silver adenocine-5'- 3-phosphate.

(7) Silver salts of macromolecular compounds:
silver polyacrylate, silver polyvinyl hydrogen phthalate, silver polystyrene sulfonate.
(8) Other silver salts:

the silver salt of 4-hydroxy-6- methyl-1,3,3a,7- tetrazaindene, the silver salt of 5-methyl-7-hydroxy-1,2,3,4,6-pentazaindene, the silver salts of tetrazaindenes as disclosed in British Patent 1,230,642; metal-containing aminoalcohols as disclosed in British Patent 1,346,595; organic acid chelates of silver as disclosed in U.S. Patent 3,794,496; silver 5-nitrosalicyl aldoxime, silver 5-chlorosalicyl aldoxime, silver salt of barbituric acid, silver

In addition, oxidizing agents such as titanium oxide, zinc oxide, gold salts of carboxylic acids, e.g., gold laurate, gold stearate, gold behenate, can be optionally employed together with the above described silver salts. Of the above described organic silver salts, comparatively light stable organic silver salts are 5 suitable when silver halides or light-sensitive complexes of silver and dyes as described in French Patent 2,089,208 are used as photocatalysts. Silver salts of aliphatic carboxylic acids containing 1i to 35 carbon atoms are particularly preferred. Such organic silver salts can be prepared according to various processes. The simplest process is to prepare organic silver salts by mixing a solution prepared by dissolving an 0 organic silver salt-forming agent or a salt thereof in a water-miscible solvent (e.g., alcohol or acetone) or water, with an aqueous solution of a water-soluble silver salt (e.g., silver nitrate) as described in U.S. Patent 3,457,075. Furthermore, it is also possible to mix a colloidal dispersion of an ammonium or alkali metal salt of an organic silver salt-forming agent with an aqueous solution of a water-5 soluble silver salt (e.g., silver nitrate) as is described in British Patent 1,347,350. In a similar process, it is also possible to use an aqueous solution of a silver complex salt (such as a silver ammine complex salt or a solution prepared by dissolving such a silver complex salt in a water-miscible solvent in place of the aqueous solution of a water-soluble silver salt such as silver nitrate. 9 As other processes, U.S. Patent 3,458,544 discloses mixing an oil-soluble solution which 20 is substantially insoluble in water (such as a benzene solution) containing dissolved therein an organic carboxylic acid with an aqueous solution of a silver complex salt to prepare a silver salt of an organic carboxylic acid. Preferably, water is added to the oil-soluble solution to prepare an emulsion before mixing with the aqueous solution of the silver complex salt. 5 Similar processing can be applied to other organic silver salts.

Japanese Patent Publication 30270/69 describes a similar process which, however, provides organic silver salts more stable against heat and light which comprises using a solution of an alkali-free silver compound, such as an aqueous solution of silver nitrate, in place of a silver complex salt. According to this process, the silver salt of benzotriazole can be 0 obtained in high yield. 30 In addition, British Patent 1,405,867 describes a process for preparing organic silver salts. This process is preferred because a thermally developable light-sensitive material using an organic silver salt obtained according to this process suffers less heat fog. According to this process, organic silver salts are prepared by mixing an emulsion of an aqueous solution of an alkali metal salt or ammonium salt of a water-soluble organic silver salt-5 forming agent and an oil (e.g., benzene, toluene, cyclohexane, pentane, hexane, a carboxylic acid ester such as an acetate or phosphate, castor oil, etc., with a silver salt (silver nitrate, etc.) or a silver complex salt, preferably as an aqueous solution. As an alternative thereof, organic silver salts can be prepared by mixing an aqueous alkali solution with an oil-soluble solution (for example, a toluene solution) of an organic silver salt-forming agent 0 and emulsifying the same, and thereafter mixing the resulting emulsion with a highly soluble silver salt such as silver nitrate or a silver complex salt such as a silver ammine complex salt, preferably as an aqueous solution. As the oil used for the preparation of the afresaid oily solutions, the following are generally used: 5 (1) phosphates: tricresyl phosphate, tributyl phosphate, mono-octyldibutyl phosphate, etc.; (2) phthalic esters: diethyl phthalate, dibutyl phthalate, dimethyl phthalate, dioctyl phthalate, dimethoxyethyl phthalate, etc.; (3) carboxylic esters: acetic esters such as amyl acetate, isopropyl acetate, isoamyl acetate, ethyl acetate, 2-ethylbutyl acetate, butyl acetate, propyl acetate, etc., sebacic esters such as dibutyl sebacate, diethyl sebacate, etc., succinic esters 0 such as diethyl succinate, etc., formic esters such as ethyl formate, propyl formate, butyl formate, amyl formate, etc., valeric esters such as ethyl valerate, etc., tartaric esters such as diethyl tartrate, etc., butyric esters such as methyl butyrate, ethyl butyrate, butyl butyrate, isoamyl butyrate, etc., adipic esters, etc.; (4) oils such as castor oil, cotton seed oil, linseed oil, tsubaki oil, etc.; (5) aromatic hydrocarbons such as benzene, toluene, xylene, etc.; (6) 5 aliphatic hydrocarbons such as pentane, hexane, heptane, etc.; and (7) cyclic hydrocarbons such as cyclohexane, etc. As the silver complex salts, there are preferably used alkali-soluble silver complex salts having a dissociation constant higher than that of the organic silver salts, such as a silver ammine complex salt, a silver methylamine complex salt, a silver ethylamine complex salt, 0 60 60

As the solvents for silver salts such as silver nitrate, there can be used polar solvents such

as dimethylsulfoxide, dimethylformamide, acetonitrile, etc., in addition to water.

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surface active agent during preparation of organic silver salts for the purpose of adjusting the grain size of the organic silver salts. Furthermore, organic silver salts may be prepared in the presence of a polymer. As a special process, it is known to mix a non-aqueous solution of an organic carboxylic acid with a non-aqueous solution of a heavy metal salt, e.g., a trifluoroacetate or tetrafluoroborate, in the presence of a polymer, to thereby prepare a heavy metal salt such as a silver salt of an organic carboxylic acid, as is described in U.S. Patent 3,700,458. U.S. Patent 3,748,143 also describes a process for preparing an emulsion using a similar non-aqueous solution.

As is described in British Patent 1,378,734 and in West German Patent OLS 2,322,096, the grain shape and grain size of organic silver salts, and the photographic properties thereof such as heat fog, light stability, sensitivity, and the like, can be changed by the presence of a metal salt such as a mercury or lead compound or a metal complex during the preparation of organic silver salts. As the metal, cobalt, manganese, nickel and iron have been confirmed to be effective in addition to the above-described mercury and lead. These metal-containing compounds may be used by mixing a mixed solution or dispersion of a solution of a silver salt-forming organic compound and the metal-containing compound with an aqueous solution of a highly soluble silver salt such as silver nitrate or a silver

complex salt such as a silver ammine complex salt with each other. Further, three components, i.e., a solution or dispersion of the metal-containing compound, an aqueous solution of a silver salt or a silver complex salt and a solution or dispersion of a silver salt-forming organic compound may be mixed with each other. Still further, mixing a solution or dispersion of a silver salt-forming organic compound with a mixed solution or dispersion of the silver salt or silver complex salt and the metal-containing compound is also preferred. The content of the metal-containing compound is preferably from about 10⁻⁶ to about 10⁻¹ mol per 1 mol of the organic silver salt and from about 10⁻³ mol to about 10⁻² mol per 1 mole of

silver halide.

The thus prepared organic silver salt grains are from about 10μ to about 0.01μ , preferably from about 5μ to about 0.1μ , in length.

The light-sensitive silver-halide used as ingredient (b) in the present invention can be silver chloride, silver bromide, silver iodide, silver chlorobromoiodide, silver chlorobromide, silver chloroiodide, silver bromoiodide or a mixture thereof. The amount thereof used ranges from about 0.001 mol to about 0.5 mol, preferably from about 0.01 mol to about 0.3 mol, per 1 mol of the organic silver salt. The light-sensitive silver halide may be coarse grain or fine grain, but the latter is preferred. A preferred grain size (length) of the silver halide ranges from about 1 μ to about 0.001 μ , preferably from about 0.5 μ to about

A light-sensitive silver halide per se can be prepared according to conventional processes known in the photographic field, such as a single jet process, double jet process, etc. For example, there can be used a Lippmann emulsion, an ammoniacal emulsion, a thiocyanateor thioether-ripened emulsion, etc. Silver halide emulsions which are not washed or which have been washed with water, alcohol or the like to remove soluble salts may be used in the present invention. A light-sensitive silver halide thus previously prepared is mixed with an

oxidation-reduction composition comprising an organic silver salt component (a), and a reducing agent, component (c), as described in U.S. Patent 3,152,904.

However, it is clear that a "pre-prepared" silver halide obtained according to the process described in U.S. Patent 3,152,904 often does not provide satisfactory light sensitivity due to insufficient contact between the silver halide and the organic silver salt, as described in U.S. Patent 3,457,075. Therefore, various technique have been developed to effect sufficient contact between the silver halide and organic silver salt. One technique comprises adding a surface active agent to a coating solution which is to form a light-sensitive layer, examples of which are described in British Patent 1,469,116. Another technique comprises mixing the prepares silver halide with the organic silver salt in a polymer, examples of which are described in U.S. Patents 3,705,565, 3,713,833, 3,706,564 and 3,761,273, British Patent 1,354,186, French Patent 2,078,586 and Belgian Patent 774,436, etc. A still another useful technique is disclosed, for example, in British Patent 1,354,186, etc., wherein a silver halide emulsion is decomposed with an enzyme, and then the resulting emulsion is mixed with an organic silver salt.

The silver halide used in the present invention may be prepared substantially simultaneously with the formation of the organic silver salt as described in German Patent Application OLS No. 2,428,125, if desired. As a specific example, a solution of a silver salt such as silver nitrate or a silver complex salt is mixed with a solution or dispersion of the as silver intract of a silver complex data is thereof containing a light-sensitive aforesaid organic silver salt-forming compound or a salt thereof containing a light-sensitive aforesaid decreinance. Or a solution of a light-

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silver salt such as silver nitrate and a silver complex salt, to thereby form light-sensitive silver halide simultaneously with the organic silver salt. It is possible to react a lightsensitive silver halide-forming ingredient (to be described hereinafter) with a previously prepared organic silver salt solution or dispersion, or to react the same on a sheet material containing an organic silver salt to thereby form light-sensitive silver halide in part of the organic silver salt. U.S. Patent 3,457,075 describes that the thus formed silver halide is in effective contact with the organic silver salt and gives good results. On the other hand, an ingredient capable of forming a light-sensitive silver halide is a compound capable of forming silver halide by acting on the organic silver salt. Such can be determined by a simple test as follows to see which compounds are effective. That is, the silver halide-forming ingredient is reacted with the organic silver salt, and, if desired, after heating, it is examined by X-ray diffraction analysis to determine whether the diffraction peak characteristic of silver halide exists or not. If the diffraction peak exists, the compound can be used. As specific examples of ingredients capable of forming a light-sensitive silver halide there 15 are illustrated the following compounds. (1) Inorganic halides: halides represented by, e.g., MXn (wherein M represents H, NH4 or a metal atom, X represents Cl, Br or I, and n represents 1 when M is H or NH4, or, when M is a metal atom, n represents the valence of the metal, where examples of the metal atom include lithium, sodium, potassium, rubidium, cesium, copper, gold, beryllium, magnesium, calcium, strontium, barium, zinc, cadmium, mercury, aluminum, calcium, strontium, barium, zinc, cadmium, mercury, aluminum, gallium, indium, lanthanum, ruthenium, thallium, germanium, tin, lead, antimony, bismuth, chromium, molybdenum, tungsten, manganese, rhenium, iron, cobalt, nickel, rhodium, palladium, osmium, iridium, platinum, etc.) (2) Halogen-containing metal complexes: for example, 25 K2PtCl6; K2PtBr6, HAuCl4, (NH4)2IrCl6, (NH4)3IrCl6, (NH4)2RuCl6, (NH4)3RuCl6, (NH4)3RbCl6, (NH4)3RhBr6, etc. (3) Onium halides: quaternary ammonium halides (e.g., trimethylphenyl ammonium bromide, cetylethyldimethyl ammonium bromide, trimethylbenzyl ammonium bromide, etc.), quaternary phosphonium halides (e.g., tetraethylphosphonium bromide, etc.), tertiary sulfonium halides (e.g., trimethylsulfonium iodide, etc.), etc., can be added to a coating dispersion just prior to coating (for example, a coating dispersion for a light-sensitive layer, a protective layer, an undercoating layer or a back coating layer) for the purpose of reducing sensitivity, and, in some cases, background density, as is described in U.S. Patent 3,679,422. Also, as is described in Japanese Patent Publication (OPI) 84443/74, a conductive high molecular weight polymer of the onium salt halide series can be used to prepare a thermally developable light-sensitive and electrosensitive material. (4) Halogenated hydrocarbons: iodoform, bromoform, carbon tetrabromide, 2-bromo-2- methylpropane, etc. (5) N-halogeno compounds: e.g., compounds which are represented by the following formulae (I) and (II) 45 (II)and N-halides containing an -SO₂NX- group (III) (where X is Cl or Br), wherein for formula (I) and (II), X represents Cl, Br or I, Z represents the atomic group necessary to 50

and N-halides containing an -SO2NX- group (III) (where X is Cl or Br), wherein for formula (I) and (II), X represents Cl, Br or I, Z represents the atomic group necessary to form a 5- to 7-membered ring which may be further condensed with another ring, A represents a carbonyl group and R₁ and R₂ each represents a hydrogen atom, an alkyl group, an aryl group or an alkoxy group, as are disclosed in detail in British Patent 1,498,956. Specific examples thereof include N-chlorosuccinimide, N-bromosuccinimide, N-bromo phthalimide, N-bromoacetoamide, N-iodosuccinimide, N-bromo phthalazone, N-bromo oxazolinone, N-chloro phthalazone, N-bromoaceto anilide, N,N-dibromobenzene sulfonamide, N-bromo-N- methylbenzene sulfonamide, 1,3-dibromo-4-, 4-dimethylhydantoin, the potassium salt of dibromoisocyanuric acid, trichloro isocyanuric acid, etc., as disclosed in British Patent Specifications Nos. 1498729 and 1498956; N-halogeno compounds of unsubstituted and substituted benzotriazoles the latter of which may be substituted with, for example, an alkyl group, most preferably an alkyl group having from 1 to 5 carbon atoms, a nitro group, a halogen atom, an imido group and an amino group; and N-halogeno compounds of benzimidazoles.

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tively added to a thermally developable light sensitive material at any time.

However, especially good results are obtained in the case where component (d) is added before or during the preparation of component (a), the organic silver salt(s). The following processes are preferably used for preparing the organic silver salts: (1) mixing a solution or a dispersion prepared by adding component (d) to a solution of a silver salt-forming organic compound with an aqueous solution of a water soluble silver salt such as silver nitrate, or with an aqueous solution of a silver complex salt such as a silver-amine complex salt; (2) simultaneously mixing three kinds of solutions consisting of a solution or a dispersion of component (d), an aqueous solution of a silver salt or a silver complex salt and a solution or a dispersion of a silver salt-forming organic compound; (3) mixing a solution or a dispersion of a silver salt-forming organic compound with a mixed solution or a dispersion prepared by

adding component (d) to a solution of a silver salt or a silver complex salt.

Further, there is a relatively preferred method, wherein component (d) is added after the preparation of component (a), and further where component (d) is added during or before the preparation of component (b). This method includes the following procedures: preparation of component (b): ing a light sensitive silver halide using a reactant solution for producing the light sensitive silver halide using a reactant solution for producing the light sensitive silver halide into which component (d) was, in advance, incorporated, according to one of the methods disclosed in U.S. Patent 3,761,273; German Patent Application (OLS) the methods disclosed in U.S. Patents 3,706,565 and 3,713,833; and British Patents 1,362,970 and 1,354,186; or adding component (d) to the reaction system for papering the light consisting 1,354,186; or adding component (d) to the reaction system for preparing the light sensitive silver halide according to the methods described above in the course of the reaction. In the case that both component (a) and the light-sensitive silver halide are produced at nearly the same time, as disclosed in German Patent Application (OLS) 2,428,125, component (d) is incorporated into one of the reactant solutions prepared for the simultaneous formation of the above-described components before or during the formation of the organic silver salt and the silver halide. In the method of converting some portion of component (a) which has been previously prepared into the corresponding light sensitive silver halide by allowing the light sensitive silver halide-forming component to act upon component (a), it is preferred to add component (d) to the reactant solution in the progress of or prior to this conversion reaction. It is not always necessary to additionally add component (d) to the reactant

solution when a trivalent or a tetravalent cerium compound is employed as a light sensitive silver halide-forming component. In any of the above-described methods, it is preferred to add component (d) in the form of a solution, but it is possible to add component (d) in the form of a dispersion prepared by dispersing it into an appropriate solvent. The addition temperature for component (d) has

no serious influence on the results of the present invention. As a guide, it is added at the temperature ranging from about 0°C to about 80°C, preferably from 10°C to 60°C.

Setting aside the mechanism of the improvements attained by the addition of component

(d) in the present invention, the following results were particularly surprising in view of the research to date by the art, i.e., the improvement in the green shelf life, the whiteness and sensitivity of the thermally developable light sensitive materials due to component (d) of the

Using pre-prepared silver halides or using the mixing method wherein an organic silver present invention. salt is mixed with a silver halide-forming reactant, improvements in photographic properties such as an enhancement of sensitivity and a reduction of heat fog can be attained by storage for a suitable period of time (for example, 20 minutes - 48 hours) at room temperature or at elevated temperature (30°C – 80°C) after the addition of the silver halide-forming agent in the presence of, if desired, a sulfur-containing compound (e.g., a thiosulfate, etc.), a metal (e.g., gold, chromium, tin, lithium, palladium, etc.), a reducing agent or a combination of

Similar improvements in photographic characteristics can be achieved by applying a these compounds. precipitation technique which is often employed in the art of producing gelatino silver halide emulsions wherein silver halide is allowed to form in the presence of a portion of a binder, the resulting silver salt is precipitated by means of a centrifugal separator, and then dispersed again into the remainder of the binder. When redispersion is carried out, the presence of nitric acid, a ferricyanide, thiocyanates, thiosulfates, benzotriazole, tetrazaindenes, mercapto compounds, thione compounds, iodides, heavy metal salts such as a rhodium salt, and the like can also be added to favorably alter photographic characteristics.

These silver halide-forming agents may be used alone or in combination. The amount thereof used ranges from about 0.001 mol to about 0.5 mol, preferably from about 0.01 mol to about 0.3 mol, per 1 mol of the organic silver salt. When the amount is less than the lower low sensitivity often results, while when the amount is more than the upper limit,

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discussed. Light sensitive complexes consisting of silver and dyes can be employed as a photocatalyst as disclosed in, for example, Japanese Patent Publication 25498/74 and Japanese Patent Applications (OPI) 4728/71 and 28221/73, and the combined use of a highly light-sensitive organic silver salt and an organic silver salt having low sensitivity is also effective, as is disclosed in Japanese Patent Application (OPI) 8522/75. Further, metal salts of diazosulfonate and sulfinic acid salts can also be used as a photocatalyst. In addition, photoconductive materials such as zinc oxide, titanium oxide, etc., can be used. Silver halide is the most suitable photocatalyst to obtain a highly sensitive thermally developable light sensitive material, however.

Silver halide produced in situ or pre-formed can be chemically sensitized using a chemical sensitizer such as a compound of sulfur, selenium, tellurium, gold, platinum, palladium, etc., a reducing agent such as silver, a tin halide, etc., or a combination thereof. Descriptions relating to such techniques are given in, e.g., U.S. Patents 1,623,499, 2,399,083, and

3,297,447.

The light-sensitive silver halide emulsions used in the present invention preferably have added thereto an anti-fogging stabilizing agent such as a triazolium salt, an azaindene, a mercury salt, urazol, sulfocatechol, an oxime, nitron, nitro-indazole, or the like, in order to stabilize them against fogging. Descriptions relevant to this art are given in, e.g., U.S. Patents 2,728,663, 2,839,405, 2,566,263, 2,597,915, British Patent 623,448, etc.

Some optical sensitizing dyes which are effective for gelatino-silver halide emulsions also show a sensitizing action for the thermally developable light-sensitive material of the present invention. As effective optical sensitizing dyes, there can be illustrated cyanines, merocyanines, complex (tri- or tetranuclear cyanines, holopolar cyanines, styryls, hemicyanines, oxonols, hemioxonols, etc. Of the cyanine dyes, those which possess a basic nucleus such as a triazoline nucleus, an oxazoline nucleus, a pyrroline nucleus, a pyridine nucleus, an oxazole nucleus, a thiazole nucleus, a selenazole nucleus, an imidazole nucleus, etc., are preferred. Such nuclei may be substituted with an alkyl group, an alkylene group, a

hydroxyalkyl group, a sulfoalkyl group, a carboxyalkyl group, an aminoalkyl group or an enamine group capable of forming a fused carbon ring or a heterocyclic ring. As to the chemical structure thereof, symmetrical and unsymmetrical dyes can be used. Also, those which possess an alkyl group, a phenyl group, an enamine group, or a hetero substituent on the methine chain or polymethine chain thereof may be used. In particular, cyanine dyes having a carboxy group are effective for sensitization. Merocyanine dyes may possess on acidic nucleus such as a thiohydantoin nucleus, a rhodanine nucleus, an oxazolidinedione

nucleus, a thiozolidinedione nucleus, a barbituric acid nucleus, a thiazolinone nucleus, a malononitrile nucleus, a pyrazolone nucleus, etc., in addition to the above-described basic nuclei. These acidic nuclei may further be substituted by an alkyl group, an alkylene group, a phenyl group, a carboxyalkyl group, a sulfoalkyl group, a hydroxyalkyl group, an alkoxyalkyl group, an alkylamine group or a heterocyclic nucleus. In particular, merocyanine

dyes having an imino group or a carboxy group are effective.

If desired, these dyes may be used as various combinations thereof. Furthermore, supersensitizing additives which do not absorb visible light such as ascorbic acid derivatives, azaindenes, cadmium salts, organic sulfonic acids, etc., as described in, e.g., U.S. Patents 2,933,390, 2,937,089, etc., may be used in combination therewith. As particularly effective sensitizing dyes for the thermally developable light-sensitive materials of the present invention, there can be illustrated merocyanine dyes having a rhodanine nucleus, a thiohydantoin nucleus or a 2-thio-2,4- oxazolidinedione nucleus, as described in U.S. Patent 3,761,279, such as 3-p-carboxyphenyl- 5-[β -ethyl-2- (3-benzoxazolylidene) ethylidene]- rhodanine, 5-[(3- β -carboxyethyl- 2-(3-thiazolinylidene) ethylidene-3- ethylrhodanine, 3-carboxymethyl- 5-[(3-methyl thiazolinylidene)- α -ethyl- ethylidene] rhodanine, 1-carboxymethyl- 5-[(3-ethyl-2- (3H)-benzoxazolylidene) ethylidene]- 3-phenyl-2-thiohydantoin, 5-[(3-ethyl-2- benzoxazolylidene)- [1-methylethylidene]- 3-[(3-pyrrolin- 1-yl)-propyl] rhodanine, 3-ethyl-5- [(3-ethyl-2- (3H)- benzothiazolylidene)-isopropylidene]- 2-thio-2,4- oxazolidinedione, 3-carboxymethyl- 5-[(3-methyl-2- (3H)-thiazolinylidene) isopropylidene] rhodanine, 3-ethyl-5-[(3- methyl-2- thiazolinylidene) ethylidene] rhodanine, 3-ethyl-5- (1-methyl-2-(1H)- pyridylidene) rhodanine, 3-ethyl-5-(3-ethyl-2-(3H)-thiazolylidene) rhodanine, 1-carboxymethyl- 5-(3-ethyl-3tion, there can be illustrated merocyanine dyes having a rhodanine nucleus, a thiohydantoin (3,4-dimethyl- 2(3H)- thiazolylidene) rhodanine, 1-carboxymethyl- 5-(3-ethyl-

2-benzoxazolylidene)- 3-phenyl-2- thiohydantoin, 1-ethyl-[3- ethyl-2-(3H)- benzoxazolidiene) ethylidene]- 3-n-butyl-2- thiohydantoin, 1-methyl-3- allyl-5-[2- (3-ethylbenzo oxazolidene- (2)-ethylidene]- 2-thiohydantoin, 1-carboxymethyl- 3-(N-methylbenzo thiazolylindyl)- 4-thia-2- thiohydantoin, 5-[(3- ethyl- 2-(3H)- naphtho -[2,1]-oxazolylidene) ethylidene]- 3-n- hepthyl-2- thiohydantoin, 3- ethyl-5-[(3- ethyl-2-(3H)nantho-12 11- avazalulidana lathulidana 1-nhanul-7-thiahudantain 3-allul-5-13- athull/2.

benzothiazolidene)ethylidene] -2-thio-2,4- oxazolidinedione, and merocyanine dyes represented by the following formulae:

The merocyanine dyes effectively used in the present invention are not intended to be construed as being limited to the above examples.

Specific examples of cyanine dyes which can be used in the present invention are illustrated below. However, the invention is not limited to the dyes specifically described below.

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In addition, trinuclear merocyanine dyes as described in U. S. Patent 3,719,495, polycyclic aromatic dyes as described in Belgian Patent 788,695, sensitizing dyes mainly for silver iodide as described in Japanese Patent Publication (OPI) 17719/74, styrylquinoline dyes as described in Japanese Patent Publication (OPI) 84637/74, rhodacyanine dyes as described in West German OLS 2,405,713, acidic dyes (e.g., 2', 7'-dichlorofluorescein dye) as described in West German Patents OLS 2,401,982, 2,404,591 and in British Patent 1,417,382, merocyanine dyes as described in British Patents 1,469,117 and 1,469,117 and Japanese Patent Application (OPI) 156,424/75 may similarly be used. Specific examples of effective merocyanine dyes having a pyrazolone nucleus are as follows:-

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These dyes are added in an amount of from about 10⁻⁴ mol to about 1 mol per 1 mol of ingredient (b), the silver halide or silver halide-forming ingredient.

Further, when silver halide is not used, the sensitizing dyes as disclosed in Japanese Patent Applications (OPI) 28221/73 and 91214/74 can also be employed. In such a case, it is more effective to heat the thermally developable light sensitive materials (up to a temperature of about 70°C to about 120°C, typically, for about 1 second to about 30 seconds) before

Ingredient (c), the reducing agent, used in the present invention is one which can reduce the image-wise exposure. organic silver salt (ingredient (a)) upon being heated in the presence of exposed silver halide. Of such reducing agents, the one actually used is decided depending upon the kind and

property of the organic silver salt used. Specific examples of the reducing agent are as follows.

(1) Substituted phenols: aminophenols; e.g., 2,4-diaminophenol, methylaminophenol, p-aminophenol, o-aminophenol, 2-methoxy-4- aminophenol, 2-β-hydroxyethyl-4aminophenol, 4-amino-2, 6-dibromophenol, 4-amino-2- methylphenol sulfate, 4-amino-3methylphenol sulfate, 4-amino-2, 6-diiodophenol, 4-amino-2,6-dichlorophenol hydrochmetnylpnenol sultate, 4-amino-2, b-dilodopnenol, 4-amino-2, b-dichloropnenol nydrochloride, N-methyl-p-aminophenol sulfate, 4-benzylideneaminophenol, 4-isopropylidene aminophenol, 4-isopropylidene amino phenol, 2,4-diamino-6-methylphenol, 4-acyl-aminophenol which contains an acryl group having 2 to 18 carbon atoms, N-acyl-aminophenol which contains an acryl group having 2 to 18 carbon atoms, N-(4-hydroxyphenyl)-aminoacetic acid, 4-hydroxyphenyl carbamic acid ethyl ester, 6-dimethylamino-3- hydroxytoluene, N-(4-hydroxyphenyl)-N'-alkyl urea which contains an alkyl group having 1 to 18 carbon atoms, N-(4-hydroxy-3, 5-di-t-butylphenyl)-N'-octadecyl urea. N-(4-hydroxy-3, 5-dichlorophenyl)-N'-octadecyl urea. 3-chloro-4- hydroxy urea, N-(4-hydroxy-3, 5-dichlorophenyl)-N'-octadecyl urea, 3-chloro-4- hydroxy diphenylamine, 4-(4-hydroxybenzylidene- amino'-2-methylphenol, 4-(4-hydroxybenzylideneamino) phenol, α , α '-bis-(4-

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		N-(2-hydroxyphenyl)- N'-alkyl urea which contains an alkyl group having 1 to 18 carbon atoms, 6-aminophenol sulfonic acid-(3)-amide, 6-amino-phenol sulfonic acid-(3)-dimethylamide, 2-amino-phenol sulfonic acid-(4)-amide, 2-benzylidene aminophenol, 4-(4-hydroxyphenylidene- amino) phenol, a, a'-bis-(2-hydroxyphenylamino)-p-xylene, 3-(2-hydroxyphenylamino)	
	5	oxo-oxolane, 4-hydroxyanilino-methane sulfonic acid, 4-hydroxy-3- methylanilino-methane sulfonic acid, 3-(4-hydroxy-3- methylanilino-methane sulfonic acid, 3-dimethylanilino-p-cresol, 2.6-di-t-butyl-p-cresol, p-ethylphenol, p-sec-hutylphenol, 2.3-dimethylphenol	5
	10	p-octylphenol, 2,4-xylenol, 2,4-di-t-butyl-phenol, 2,r,5-trimethylphenol, p-nonylphenol,	10
		ethylphenol, 2,4,6-tri-t-amylphenol, 2,6-di-t-butylphenol, 2-isopropyl-p-cresol, 3-methyl-3- (3-methyl-4- hydroxyphenyl)- pentane, 2,6-di-t-butyl-4- nonylphenol, 2,4-di-t-butyl-6- nonyl- phenol; aryl substituted phenols, e.g., p-phenylphenol, o-phenylphenol, a-phenyl-o-cresol; other phenols, e.g., p-acetophenol, p-acetoacetylphenol, 1,4-	
	15	dimethoxybenzene, 2,6- dimethoxyphenol, chlorothymol, 3,5-di-t-butyl-4- hydroxybenzyl-dimethylamine, 2,6-di-cyclohexyl-p-cresol, 2,6-di-t-butyl-4- methoxymethylphenol, 4-methoxyphenol, 2-methyl-4- methylmercapto-phenol, 2,6-dicyclopentyl-p-cresol, 2-t-butyl-6- cyclohexyl-p-cresol, 2,5-dicyclopentyl-p-cresol, 2,5-dicyclopentyl-p-cresol, 2,5-dicyclopentyl-p-cresol, 2,5-dicyclohexyl-p-cresol, 2-cyclopentyl-4- t-butyl-phenol, 3,5-di-t-butyl-4- bydroxy	15
	20	dehyde, 3,5-di-t-butyl-4-hydroxy cinnamic acid, 3,5-di-t-butyl-4- hydroxybenzal- dehyde, 3,5-di-t-butyl-4- hydroxy cinnamic acid ethyl ester and sulfonamide phenols as disclosed in U.S. Patent 3,801,321; polyvinyl-(2-hydroxy-3- methoxybenzal); hydroxyin- danes as disclosed in German Patent Application (OLS) 2,319,080; hydroxycumarones and hydroxycumaranes as disclosed in U.S. Patent 3,819,382; and novolak resin reaction pro-	20
	25	o- or p-t-butylphenol, 2,6-di-t-butylphenol and mixtures thereof). (2) Substituted or unsubstituted bis, tris and tetra-kisphenols: o-bisphenols [e.g., 1,1-bis-(2-hydroxy-3, 5-dimethyl-phenyl)-3,5,5-trimethylhexane, bis(2-hydroxy-3-t-butyl-5-methyl-phenyl) methane, bis(2-hydroxy-3, 5-di-t-butylphenyl)-methane, bis (2-hydroxy-3, 6-di-t-butylphenyl)-methane, bis (2-hydroxy-3, 6-di-t-butylphenylph	25
,		hydroxy-3-t- butyl-5- ethylphenyl) methane, 2,6-methylenebis(2- hydroxy-3- t- butyl-5-methylphenyl)-4- methylphenol, 1,1-bis(5-chloro-2- hydroxyphenyl) methane, 2,2'œ methylenebis [4-methyl-6- (1-methylcyclohexyl) phenol], 1,1-bis-(2-hydroxy-3,5-dimethyl-phenyl)-2- methylpropane, 1,1,5,5-tetrakis-(2-hydroxy-3,5-dimethylphenyl)-2, 4-ethylpentane, 3,3', 5,5'-tetramethyl-6, 6'-dihydroxy-triphenyl	30
	35	di-t-butylphenyl)-ethane, 1,1-bis(2-hydroxy-3, 5-di-t-butylphenyl)-propane, 1,1-bis- (2-hydroxy-3, 5-di-t-butylphenyl) butane and 1,1-bis(2-hydroxy-3,5-di-t-amylphenyl) ethane) 1,1-bis(2-hydroxy-3-cyclohexyl-5-t-butylphenyl) methane, 1,1-bis(2-hydroxy-3-cyclopentyl-5-t-butyl-phenyl)-2,2-dimethylethane his(2-hydroxy-3-cyclopentyl-5-t-butyl-phenyl)-2,2-dimethylethane	35
,	40	butane, 1,1-bis(2-hydroxy-3- cyclopentyl-5-t-butylphenyl) butane, 1,1-bis(2-hydroxy-3- cyclopentyl-5-t-butylphenyl) methane, 1,1-bis(2-hydroxy-3, 5-di-cyclopentyl-6- methyl- phenyl) methane, 1,1-bis(2-hydroxy-3,6-di-cyclopentyl-5- methyl- phenyl) methane, bis(2-hydroxy-3- cyclopentyl-5- t-butylphenyl) sulfide, bis(2-hydroxy-3- cyclopexyl-5-t-butylphenyl) sulfide, 1,1-bis(2-hydroxy-3- t-butylphenyl)	40
	45	butyl-5- methyl-phenyl) sulfide, 1,1-bis(2-hydroxy-3, 5-dimethylphenyl) methane, 1,1-bis(2-hydroxy-3, 5-di-t-butylphenyl)-2- methylpropane, 1,2-bis(2-hydroxy-3-t-butyldibenzofuryl) ethane, and 3,3', 5,5'- tetra-t-butyl-6, 6'- dihydroxytriphenyl methane]; p-bisphenols (e.g., bisphenol A 44'-methylenebis(3-methyl-5-t-butyl-6, 2) A 44'-methylenebis(3-methyl-5-t-butyl-6, 2)	45
	50	dihydroxybiphenyl, 1,1-bis(4-hydroxyphenyl)- cyclohexane, 2,2-bis(3,5-dibromo-4-hydroxyphenyl) propane, 2,2-bis (3,5-dichloro-4-hydroxyphenyl) propane, 2,2-bis(3,5-dibromo-4-hydroxyphenyl) propane, 2,2-bis(3,5-dibromo-4-hydroxyphenyl)	50
	55	bis(3-methyl-4- hydroxy-5-t- butylphenyl) sulfide, 2,2-bis(4-hydroxy- 3,5-di-t-butylphenylthio) propane, 4,4'-butylidenebis(6-t-butyl- 3-methylphenol), 4,4'-thiobis (6-t-butyl-3-methylphenol), 4,4'-thiobis (6-t-butyl-2-methylphenol), 4,4'-ethylidenebis (6-t-butyl-phenol), 4,4'-ethylidenebis (6-t-butyl-o-cresol), 4,4'-ethylidenebis (2-t-amylphenol), 4,4'-(p-chlorobenzylidene)-di-(2,6-xylenol), 4,4'-ethylidene-bis (2-cyclohexylphenol), 4,4'-pentylidene-di-(o-cresol), 4,4'-ethylidene-bis (2-cyclohexylphenol), 4,4'-pentylidene-di-(o-cresol),	55
	60	4,4'- (p-bromo-benzylidene)- di-phenol, 4,4'-propylidene-bis (2- phenylphenol), 4,4'æ ethylidene-di-(2,6-xylenol), 4,4'-heptylidene- di-(0-cresol), 4,4'- ethylidene-bis (2,6-di-t-butylphenol), 4,4'-(2-butenylidene)-di-(2,6-xylenol), 4,4'-(p-methylbenzylidene)- di-(0-	60

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The most preferred reducing agents are 2,4-dialkyl substituted orthobisphenols, 2,6-

dialkyl substituted parabis-phenols or mixtures thereof. For example, reducing agents represented by the following general formulae are very preferred for use in the present inven-

tionally be employed, if desired.

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wherein R^1 , R^2 , R^5 and R^6 each represents an alkyl group constaining one to five carbon atoms, a cyclopentyl group or a cyclohexyl group, and R^3 , R^4 , R^7 and R^8 each represents a hydrogen atom, an alkyl group containing one to eight carbon atoms, an aryl group (e.g., a phenyl group, or a napththyl group), a substituted aryl group (e.g., a carboxyphenyl group, a halogen substituted phenyl group, an alkoxy substituted phenyl group, a nitro substituted phenyl group, etc., as are disclosed in detail in German Patent Application (OLS) 2,321,328), or an aralkyl group (e.g., a benzyl group, β -phenylethyl group. Suitable reducing agents are selected depending upon the kind (property) of the organic

Suitable reducing agents are selected depending upon the kind (property) of the organic silver salt(s) used (ingredient (a)). For example, a stronger reducing agent is suitable for silver salts which are comparatively difficult to reduce such as the silver salt of benzotrizole, silver behenate, etc., whereas weaker ones are suitable for silver salts which are comparatively easy to reduce such as silver captrate, silver laurate, etc. As the reducing agent for the silver salt of benzotriazole, there are for example, 1-phenyl-3- pyrazolidones. As the reducing agent for

silver behenate, there are many compounds such as o-bisphenols of the bis(hydroxyphenyl) methane series. Also, as the reducing agent for silver captrate and silver laurate, there are for example substituted tetrakisphenols, o-bisphenols of the bis- (hydroxyphenyl) alkane series, p-bisphenols (e.g., a bisphenol A derivative), p-phenylphenols. Acceptable reducing agents/organic silver salt combinations can easily be determined by a simple test. For example, a sample of the reducing agent is mixed with a coating solution containing the organic silver salt, and the mixed coating solution coated on the support. The resulting heat-developable light-sensitive sample is then exposed and heated; examination at this stage

easily permits one skilled in the art to determined optimum combinations.

The amount of the reducing agent used in the present invention varies depending upon the kind of the organic silver salt or the reducing agent and upon other additives, but, in general, a

suitable amount ranges from about 0.05 mol to about 10 mols, preferably from about 0.1 to about 3 mols, per 1 mol of the organic silver salt.

The above-described various reducing agents may be used as combinations of two or more thereof. Specific examples of using two reducing agents in combination are described in Japanese Patent Application (OPI) 115540/74 and U.S. Patents 3,667,958, and 3,751,249. As a particularly effective combination of rreducing agents, there are illustrated the combination of at least one carboxylic acid ester derived from a phenol having a bulky o-substituent and an o- or p-bisphenol, the carboxylic acid ester being the aforesaid ester between a carboxylic acid derived from a phenol having a bulky o-substituent and a mono- or polyhydric alcohol or a phenol or the ester between an alcohol derived from a polyhydric phenol having a bulky o-substituent. or from a phenol having a bulky o-substituent and a mono- or poly-carboxylic acid. This combination enables one to attain a reduction of heat fog, an increase in whiteness and a stabilization against light exposure after processing. In addition, the combined use of two mono- or poly-phenolic reducing agents having alkyl groups at the two substitution positions adjacent the hydrocy-substituted position of the aromatic nucleus is effective for preventing discoloration upon exposure to light. Further, it has been confirmed that development can be accelerated by the combined use of a compound of tin, iron, cobalt or nickel, for example, a metal salt of a long chain fatty acid, e.g., iron stearate, lead behenate (such compounds are auxiliary reducing agents), and the reducing agent. The amounts of these auxiliary reducing agents vary widely depending upon the reducing power of the main reducing agent and the auxiliary reducing agent and the reducibility of the oxidizing agent (the organic silver salt), but, in general, they are used in an amount of from about 10.5 to about 1 mol, preferably from 10.3 to 0.8 mol, per 1 mol of the main reducing agent.

A color toning agent can be used together with these reducing agents. The color toning agent is preferably used for producing images of a dark tone, especially a black tone. The color toning agent is most effective when used in a concentration ranging from about 0.0001 mole to about 2 moles, preferably from about 0.0005 mole to about 1 mole, per mole of the organic silver salt. The choice of an effective toning agent is made according to the organic silver salt and the reducing agent used. The most commonly used color toning agents include heterocyclic organic compounds contain-

ing a -C-N- unit (wherein R represents a hydrogen atom, a

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hydroxy group, a metallic ions such as Na+, Li+, Ag+ or K, an acyl group having 2 to 10 carbon atoms such as an acetyl group, a propionyl group, etc., and the like) such as phthalazinones, atoms such as an accept group, a propiony group, etc., and the fixey such as printal actions, oxazinediones, cyclic imides, quinazolinones, N-hydroxyphthalimides, urazoles, 2-pyrazoline-5- ones and the like. Specific examples of color toning agents of this kind are; phthalazinone, 2-acetylphthalazinone, 2-phthalyl-phthalazinone, N-methylphthalazinone, 2-pivaloylphthalazinone, 2- carbamoylphthalazinone, 2-(3,4-dimethoxybenzoyl) phthalazinone, 2-lauroylphthalazinone, 2-benzoylphthalazinone, 2-(p-methoxy-benzoyl) phthalazinone, 2-ethoxy formyl phthalazinone, phthalazinone derivatives as disclosed in W. German Patent Application OLS 2,449,252 and U.S. Patent 3,844,797; phthalazinone salts 5 such as phthalazinone silver, quinazolinediones and benzoxazinediones or naphthooxazinediones as disclosed in Japanese Patent Applications (Laid-Open) 91215/74 and 2524/ 75, cyclic imides such as substituted phthalimides as disclosed in German Patent Applications 10 (OLS) 2,140,406 and 2,141,063; quinazolines as disclosed in U.S. Patent 3,846,136; pyrazoline-5-ones, N-hydroxynaphthalimides as disclosed in U.S. Patent 3,782,941; mercapto compounds as disclosed in U.S. Patent 3,832,186 and Japanese Patent Application (Laid-Open) 5020/74, phthalazinediones as disclosed in U.S. Patent 3,885,967, uracils as disclosed in German Patent Application OLS 2,506,320, barbitals, saccharin, 15 5-nitrosaccharin, phthalic anhydride, 2-mercaptobenzoxazole, 2-hydroxybenzothiazole, 2-amino-6-methyl benzo thiazole, 2-amino-4- (4-biphenylyl)- thiazole, imidazole, 2-amino-6-methyl benzo thiazole, 2-amino-4- (4-biphenylyl)- thiazole, imidazole, 2-amino-6-methyl benzo thiazole, 2-amino-6-methyl 2-hydroxybenz imidazole, N,N'-ethylene-thiourea and 1-acetyl-2- thiohydantoin. Also, the combined use an imidazole and phthalic acid or naphthoic acid or phthalamide acid can gives images of a black tone, as disclosed in U.S. Patent 3,847,612. Another 20 preferred example is the combined used of phthalazinone and 2-acylphthalazinone. The simultaneous use of two or more kinds of the above-described color toning agents can produce various desirable photographic results. The color toning agents may be incorporated in the support in a backing layer, in a subbing layer provided on the support or in the finally 25 coated layer. Good results can be obtained in all cases. Various methods can be used to further prevent thermal fog from occuring in thermally developable light sensitive materials of the present invention. For this purpose, N-halogeno compounds such as N-halogenosuccinimide, N-halogenoacetamide, N-halogenooxazolinone, N-halogenobenzo-triazole, N-halogenobenzimidazole, N,N'œ dichloro-1, 2-ethylene- bisbenzamide and the like can be employed, as disclosed in, for 30 example, Japanese Patent Applications (Laid-Open) 10724/74, 97613/74 and 90118/74, and British Specification 1498730. In another method for preventing thermal fog, a wide variety of acidic compounds and salts thereof can be employed, as disclosed in Japanese variety of acidic compounds and salts thereof can be employed, as disclosed in Japanese Patent Applications (Laid-Open) 125016/74, 130720/74, 89720/73, 75433/76, 52818/76 and 54428176; U.S. Patent 3,645,739; and German Patent Application OLS 2,445,038 and British Patents 1,476,875, 1,542,470 and 1,523,127. Specific examples of these acids include lauric acid. Patricia acid. 35 lauric acid, myristic acid. palmitic acid, stearic acid, behenic acid, succinic acid, maleic acid, tetrahalogeno phthalic acid or the anhydrides thereof, aryl sulfonic acids such as benzene sulfonic acid and p-toluene sulfonic acid, aryl sulfinic acids such as benzene sulfinic acid and p-toluene sulfinic acid or the salts thereof, citric acid, rosins which have an oxidation value 40 greater than 120 e.g., gum rosin, wood rosin, hydrogenated rosin, etc., salicyclic acid, alkyl substituted benzoic acids such as p-hydroxybenzoic acid, 2,6-dihydroxybenzoic acid, tetrabromobenzoic acid, p-acetoamide benzoic acid, p-t-butylbenzoic acid and the like, phthalic acid, isophthalic acid, trimellitic acid, pyromellitic acid, diphenic acid, 5', 5'-methylenebis-45 salicyclic acid, capric acid, arachidic acid, lignoceric acid, cerotic acid, linolic acid, oleic acid, adipic acid, sebacic acid, dimethyl stearic acid, dimethyl behenic acid, cinnamic acid, o-phthalamine acid, diterpenes, e.g., abietic acid, pimaric acid, iso-d-pimaric acid, neoabietic acid, levoabietic acid and the like, alkali salts or esters of benzenethiosulfonic acid and combinations thereof. As examples of proper combinations, mention may be made of the combination of a sulfinic acid and a polyhalogenophthalic acid, the combination of a sulfinic 50 acid and a rosin, the combination of a sulfinic acid and a diterpenic acid and the combination of a thiosulfonic acid and an imidazole. Lithium salts of higher fatty acids such as lithium myristate, lithium stearate, lithium behenate, lithium palmitate, lithium laurate and the like can be employed as a thermal fog 55 stabilizer: As other examples of compounds which can effectively precent thermal fog from occurring mention may be made of benzotrizole and derivatives thereof, phenyl mercapto tetrazoles, thiouracils as disclosed in British Patent 1,498,728, for example, 2-thiouracils 60 represented by the following formula;

of M. is

955,061. Surface active agents, for example, saponin and alkyl aryl sulfonates as disclosed in,

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into the thermally developable light sensitive materials of the present invention. Certain layers of the thermally developable light sensitive elements, for example, a lightsensitive layer, which undergo a hardening treatment, can be hardened using various organic and inorganic hardeners in the practice of the present invention. Hardening agents can be used either singly or in combination. Preferred examples of hardeners include aldehydes, blocked aldehydes, ketones, carboxylic acids and carbonate derivatives, sulfonate esters, 5 sulfonyl halides, vinylsulfonyl esters, active halogeno compounds, epoxy compounds, aziridenes, active olefins, isocyanates, carbodiimides, polymeric hardeners such as dialdehyde starchs, and so on. Further, various additives can be added to increase image density. For example, compounds containing -CO-, -SO- or -SO₂- groups as disclosed in, for example, U.S. Patent 10 3,667,959; and non-aqueous organic polar solvents such as tetrahydrothiophene-1, 1-dioxide, 4-hydroxybutanonic lactone and methylsulfinyl methane are suitable for this purpose. Besides these, acetates of zinc, cadmium and copper as disclosed in U.S. Patent 15 3,709,304 are effective. Further, compounds which change into alkaline compounds on heating such as the com-15 pounds containing water of crystallization as disclosed in U.S. Patents 3,635,719 and 3,531,285; guanidinium salts, acidic salts of amines and metal oxides or hydroxides are effective for accelerating development. For the purpose of increasing the developing speed, moisture-releasing agents can be optionally added. Moisture-releasing agents include not only the above-described compounds containing water of crystallization and metal hydrox-20 ides, but also ureas, caprolactam, p-nitroethanol, β -cyanoethanol, glycol, polyethylene glycol, glycerol, sorbitol, and mono- or oligo-saccharides. Besides the above-described additives, the combination of a polyalkylene glycol and mercaptotetrazole can also be employed to improve sensitivity, contrast and image density. Moreover, leuco-dye compounds as disclosed in British Patent 1,441,377 can be employed to 25 further improve the green shelf life. Further, it is possible to increase the whiteness by blueing by the addition of blue dyes such as Victoria Blue to result in an improvement of the residual color produced by the dyes. In the thermally developable light sensitive materials of the present invention, a subbing layer may be provided between the support and the heat developable light sensitive layer(s) 30 coated on the support. Polymer acids containing a behenic acid unit, a palmitic acid unit, a lauric acid unit, a rosin unit, a diterpenic acid unit, a polyacrylic acid unit, a maleic acid unit or an acrylic acid unit, benzotriazoles, mercaptoazoles, metal salts of fatty acids such as lithium laurate, lithium behenate, etc., and so on can be incorporated into the subbing layer to improve photographic 35 characteristics such as the color change by light and thermal fog. Further, it is possible to prevent the emulsion from permeating into the support and to increase resolution by incorporating matting agents such as clay, kaolin, starch, barium sulfate, alumina, silica, titanium dioxide, zinc oxide and the like into the subbing layer. Also, a conductive metal layer 40 produced by an electrolytic process may be used as a subbing layer. Moreover, a polymer layer is preferably provided on the back side of a paper support to increase moisture resistance, to protect the support from curling, to facilitate note making and to prevent color toning agents or sublimating compounds from transfering from emulsion layers or the like. Polymers employed for the back layer include gelatin, polyvinyl alcohol, polyvinyl pyrrolidone, cellulose acetate butyrate, acrylate copolymers, polyamide 45 resins, coumaron-indene resins, cellulose diacetate, ethyl cellulose, the above-described polymers employed for the subbing layer and binders for emulsions as described hereinafter. This back polymer layer can additionally contain the above-described color toning agent and reducing agents, dyes and other additives. Further, thermally developable light sensitive materials which have a back layer containing a heat transferable dye can be employed as a thermally transfer material. As to these thermally transfer materials, descriptions are given in patents such as U.S. Patent 3,767,394 and Japanese Patent Application (Laid-Open) A polymer final coat can optionally be provided on a light sensitive layer to increase the 55 transparency of a thermally developable light sensitive layer, increase image density, and improve upon the green shelf life, as disclosed in Japanese Patent Applications (Laid-Open) 6917/74 and 128726/74, Japanese Patent Application (OPI) 46316/75, Belgian Patent 798,367; and U.S. Patents 3,856,526 and 3,856,527. A polymer final layer coated in a

thickness ranging from about 1 micron to about 20 microns is most suitable for use. Suitable

polymers for the polymer layer include polyvinyl chloride, polyvinyl acetate, vinyl chloridepolymers for the polymer layer metade polymethylmethacrylate, methylcellulose, ethylcel-vinyl acetate copolymers, polystyrene, polymethylmethacrylate, methylcellulose, ethylcel-vinyl acetate copolymers, polystyrene, polymethylmethacrylate, methylcellulose, ethylcel-

undercoated paper, glassine paper, kent paper, man overlay coated paper, paper having a

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so on

Besides the above, an aluminium plate under-coated with polyacrylamide, an aluminium plate having received a treatment with a hydrophilic silicate, and a support containing as a subbing layer a conductive metal layer can be also used.

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Patterns can be optionally engraved on either the upper layer or the back layer of the support. Engraving of this kind is required for making a post car or a commutation ticket. The above-described various kinds of layers are generally provided on one of the aforesaid supports, but some components can be incorporated into the the support itself. Incorporation of some components into a support such as a plastic film, glass or metal film is, of course, accompanied with many difficulties in permitting the components to efficiently execut their

accompanied with many difficulties in permitting the components to efficiently exert their intended effect. However, the incorporation of some components into a paper support permits the components to exert their effect to the same extent as the incorporation of them into any layer provided on a support.

An anti-foggant, a toning-agent and an anti-halation-agent are examples of materials which may be incorporated into the support. In the present invention, an organic silver salt, a photocatalyst and, optionally, a sensitizing dye can be incorporated in the same layer (i.e., this layer is called a photosensitive layer) if desired).

Other ingredients of the present invention (such as a reducing agent, a toning agent, an anti-fogging agent and an ultraviolet absorbing agent, etc.) can be incorporated in the above photosensitive layer, or another layer on the support such as the subbing layer or a protective layer, if desired.

In the present invention, it is most preferred to incorporate an organic silver salt, a photocatalyst, a reducing agent, a toning agent, an antifoggant and a binder in one layer on the support

The light sensitive composition is coated on a support at the coverage ranging from about 0.2 g to about 3 g, preferably from about 0.3 g to about 2 g, in terms of silver content in both the organic silver salt and the silver halide, per square meter of support. When the coating amount is less than the aforesaid lower limit, the maximum density of the resulting image becomes too loaw, while there is a tendency for the maximum density of the image to be saturated in the range more than the upper limit. Therefore, an excess amount of coating over

saturated in the range more than the upper limit. Therefore, an excess amount of coating over the aforesaid upper limit increases the cost of the product.

One preparation method for thermally developable light sensitive materials which can be

employed in the present invention is roughly illustrated below. Namely, the organic silver salt-forming agent is allowed to react with a silver ion-donating agent (e.g., silver nitrate) according to one of the previously-described various methods to result in the production of the organic silver salt. It is preferred to add component (d) in the course of or prior to the organic silver salt-producing process. The preparation procedure is usually carried out at atmospheric pressure and at an appropriate temperature ranging from -50°C to +80°C, particularly from about 20°C to about 60°C. The resulting organic silver salt is washed with water, an alcohol or the like, and then dispersed into a binder for emulsion formation by means of a colloid mill, a mixer, a ball mill or the like. The dispersion is usually carried out at ordinary temperature (15°C to 25°C). A silver halide-forming agent is then added to the thus obtained polymer dispersion of the silver salt to convert some portion of the organic silver salt into the corresponding silver halide. An approximate reaction temperature is in the range of ordinary temperature to 80°C, and a proper reaction time can be arbitrarily chosen in the

range of from about 1 minute to about 48 hours. As earlier described, a previously prepared silver halide may be added to the aforesaid dispersion, or an organic silver salt and silver halide can be produced at the same time. It is preferred to add component (d) in the course of or prior to the silver salt-forming process. Various additives such as sensitizing dyes, reducing agents, color toning agents and so on are then added, preferably in the form of a solution, in the order of description. At this time, component (d) may be also added. Usually, the components are added in turn with stirring at a temperature ranging from ordinary temperature to 50°C at an appropriate time interval (usually 5 to 20 minutes). The thus prepared coating solution is coated on a proper support without drying. In order to provide a final coat polymer layer, a subbing layer, a back layer and other layers, the respective coating solutions

polymer layer, a subbing layer, a back layer and other layers, the respective coating solutions are prepared in a manner similar to the above, and are coated in turn by dipping, air-knife coating, curtain coating or hopper coating. Two or more layers may be optionally coated simultaneously according to a method as disclosed in U.S. Patent 2,761,791 and British Patent 837,095.

If desired, printing can be carried out on the surface or the back of the support, or a layer

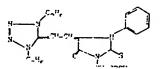
provided on the support, to produce a commuter or like ticket, a post card or other writings.

The thus prepared heat developable light sensitive material is cut to an appropriate size, if necessary, and then subjected to image-wise exposure. The resulting material can be optionably pre-heated (up to 80°C to 140°C) before the image-wise exposure. Light sources

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copying which is chiefly employed for the exposure of diazo light sensitive materials, a mercury lamp, a xenon lamp, a CRT-light source, a laser and so on. As an original, not only can line image such as a drafting be used but also photographic images with gradation, portraits and scenic images taken with a camera can be used. The printing techniques applicable to the present invention include contact printing 5 5 5 wherein the original is closely superposed on the sensitive material, reflection printing and enlargement printing. The exposure amount depends upon the sensitivity of the sensitive material obtained. As a guide, about a 10 lux.second exposure amount is required for high sensitivity materials, while about a 104 lux.second exposure amount is required for low) sensitivity materials. 10 10 The thus image-wise exposed sensitive material can be developed merely by heating (up to about 80°C to about 180°C, preferably up to about 100°C to about 150°C). The heating duration for developing is arbitrarily controlled in the range of 1 to 60 seconds. It depends upon the heating temperature. Usually, about 5 to 40 seconds' heating is required at 120°C about 2 to about 20 seconds' heating is required at 130°C, and about 1 to about 10 seconds' į 15 heating is required at 140°C. A wide variety of means can be used for heating the sensitive material. For example, the sensitive material may be allowed to come into contact with a simple heated plate or with a heated drum. According to circumstances, the sensitive material may be allowed to pass through a heated space. In addition, it may be heated by using high frequency waves or a laser) 20 beam. The odor generated on heating can be masked by using a processing machine equipped with a deodorant. Perfumes can be incorporated in the sensitive material so as to mask the odor generated from the sensitive material on heating, as disclosed in Japanese Patent Application (OPI) 10925/76. The thermally developable light sensitive materials prepared in the present invention have, 25 in general, the character of easily undergoing deterioration when they are in contact with moisture. Therefore, it is desirable that the finished sensitive materials be packed together with a dessicant when shipped as a commodity, as disclosed in Japanese Patent Application (Laid-Open) 2523/75. In accordance with a preferred embodiment of the present invention, thermally develop-) 30 able light sensitive materials of excellent green shelf life exhibiting a high degree of whiteness and high sensitivity are provided. The present invention will now be illustrated in greater detail by the following examples. EXAMPLĒ I 1.9 g of sodium hydroxide was dissolved in 100 ml of water. This water solution was mixed i 35 with a solution prepared by dissolving 12 g of lauric acid into 100 ml of toluene to form an emulsion (at 25°C). An aqueous solution of 8.5 g of silver nitrate dissolved in 50 ml of water and an aqueous solution of 0.3 g of (NH₄)₂Ce(NO₃)₆ dissolved in 25 ml of water were simultaneously added to the emulsion at 21°C. The addition rate of both solutions was adjusted so as to be the same. At the conclusion of dropwise addition of the aqueous solution) 40 of silver nitrate, the emulsion separated into an aqueous phase and a toluene phase containing silver laurate. After removal of the aqueous phase, precipitates (cerium-ion-containing silver laurate) were collected from the toluene phase by centrifuging. The precipitate was dispersed into a polymer solution, which was produced by adding 23.5 g of polyvinyl butyral (polymerization value 1000) to 160 ml of isopropanol, by means of a 45 45 homogenizer to prepare a polymer dispersion of the silver salt (wherein about 1/20 mole of silver laurate was contained). An 80 g portion of the polymer dispersion of the silver salt was kept at 50°C, and 16 cc of 1.1 wt% of an N-bromoacetamide solution in acetone was added thereto with stirring, and rhe reaction system allowed to stand for 60 minutes while heating was continued to maintain it at 50°C. 50 After chill-setting the resultant dispersion at 30°C, the following components were added 50 in their order of description every 5 minutes to the resultant dispersion as the stirring was continued. COMPONENTS 55 (a) Sensitizing Dye (merocyanine dye having the following formula)



(0.025 wt% 2-methoxyethanol solution) 10 ml

[Other merocyanine dyes, other cyanine dyes and acidic dyes instead of this dye can be used in a similar manner.]

(b) Antifoggant

Sodium thiobenzene sulfonate (0.02 wt % methanol sulution)

24 ml

(c) Antifoggant ...

Rosin (oxidation value 162; Staybelite Rosin, produced by Hercules Powder, Inc.) (10% wt% ethanol suliton)

8 ml

(d) Antifoggant

Benzotriazole (0.15 wt% methanol solution)

12 ml

(e) Color Toning Agent

Phthalazone (3 wt% methanol solution)

32 ml

Reducing Agent

(24% wt% acetone solution) 40 ml
The thus prepared coating dispersion was coated on art paper at a coverage of 0.4 g of silver per square meter. Thermally developable light sensitive material A was thus obtained. For purposes of comparison, thermally developable light sensitive material B was prepared in the same manner as the sensitive material A except that the addition of (NH₄)2Ce(NO₃)6

was omitted.

The thus produced heat developable light sensitive materials A and B were each exposed to tungsten light through a wedge (3 × 10³ lux.sec.) and developed by heating at 140°C for 8 seconds. They were then subjected to sensitometry. Identical samples of thermally developable light sensitive materials A and B were allowed to stand for 7 days at 35°C in an atmosphere containing moisture at a relative humidity of 80% and then subjected to sensitometry as above. The results are shown in Table 1.

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	Sensitive Material			B (Comparison)
5	Sensitivity*		330	100 5
	Fog	,	0.14	0.18
	Dmax		1.13	1.14
10.;	∇ D **	•	0.05	0.15 10

*The relative value obtained when the sensitivity of sensitive material B is set as 100.

**The value obtained by substracting the fog value observed just after heat development was completed from the fog value observed after the overall exposure to a fluorescent lamp.

As is apparent from the results in Table 3, sensitive material D shows a more improved sensitivity and color change by light.

Thermally developable light sensitive material E was prepared in the same manner as sensitive material A in Example 1 except that 20 mg of Ce(NO₃)₃.6H₂O was added instead of (NH₄)₂Ce(NO₃)₆. Sensitive material B (employed for comparison) and the sensitive material E were compared following processing as in Example 3 and under the same conditions as in Example 3.

Regarding the degree of whiteness after the overall exposure, sensitive material E was more excellent. The results of testing are shown in Table 4.

Table 4

30 -	Sensitive Material	E	B (Comparison)	30
	Sensitivity Fog	280	100	
	Fog	0.15	0.18	
35 -	Dmax ·	1.15	1.41	35
	ΔD	0.07	0.15	33

As is apparent from the results in Table 4, sensitive material E has improved sensitivity and color change by light.

EXAMPLE 5

Thermally developable light sensitive material F was prepared in the same manner as sensitive material A in Example 1 except that 12 g of stearic acid was used instead of lauric acid, 20 ml of 20 wt% acetone solution of the reducing agent having the following formula

$$(\operatorname{CH}_{\tau})_{\tau^{C}} \xrightarrow{\operatorname{Cu}} \overset{\operatorname{H}}{\underset{C \mapsto \operatorname{H}}{\bigoplus}} \overset{\operatorname{C}(\operatorname{CH}_{\tau})_{\tau}}{\underset{C \mapsto \operatorname{H}}{\bigoplus}} (\operatorname{CH}_{\tau})_{\tau}$$

was added instead of reducing agent (f) having the following formula

	- 1	•
т.		

5			Sensitive Material A	Sensitive Material B	5
		Sensitivity*	103	100	
	Fresh	Fog	0.17	0.18	10
10	• .	Dmax	1.45	1.41	
		Sensitivity*	107	120	
15	35°C, 80% Fog	0.20	0.80	15	
	After 7 Days	Dmax	1.35	1.33	-

*The reciprocal of the exposure amount required to provide a density of $\log + 0.1$, and the relative value obtained when the sensitivity of sensitive material B is set as 100. 20 As is apparent from the results in Table 1, sensitive material A of the present invention had

an excellent green shelf life.

EXAMPLE 2 Thermally developable light sensitive material C was prepared in the same manner as sensitive material A in Example 1 except that 0.2 g of Ce(SO₄)₂ was added instead of 25 (NH₄)₂Ce(NO₃)₆. Development and sensitometory were carried out under the same conditions as in Example 1. The results are shown in Table 2.

30		Tab	В	30	
		Sensitive Material	C	(Comparison)
		Sensitivity	95	100	35
35	Fresh	Fog	0.18	0.18	<i>JJ</i>
		Dmax	1.35	1.41	
	- = O - O - O - O - O - O - O - O - O -	Sensitivity	99	120	40
40	35°C, 80% After 7 Days	Fog	0.25	0.80	
	Altor / Days	Dmax	1.30	1.33	

As is apparent from the results shown in Table 2, sensitive material C of the present 45 invention had an excellent green shelf life.

EXAMPLE 3 Thermally developable light sensitive material D was prepared in the same manner as sensitive material A in Example 1 except that 24 mg of CeBr3.5H2O was added instead of (NH4)2Ce(NO3)6. Sensitive material B (for comparison) and sensitive material D were each

developed and subjected to sensitometry under the same conditions as in Example 1.

Developed materials B and D were each exposed to a fluorescent lamp (10,000 lux, 10 hours) over the whole surface thereof. Then, the increase in background density (image-free areas) was examined. With respect to the degree of whiteness after overall exposure, sensitive material D was more excellent than sensitive material B.

:4	4	25		1,545,4			25_	
			and stencil paper for a pre- was used instead of art p For the purpose of co	aper. mparison, thermally	developable light sen-	sitive material G was		
5		5	prepared in the same ma added. Each of the sensitive m sensitometry under the sa	naterials F and G was	subjected to develop	nent and subjected to)	
10	-	10		Tabl	e 5	•	10	
			Sensitive Mate	નંગી	F	G		
			Scisiare mate	Sensitivity	103	100		
15		15	Fresh	Fog Dmax	0.17 1.30	0.20 1.25	15	
			•					
			3.500, 00%	Sensitivity	100	95		
20	- 1	20.	35 ⁰ C, 80% After 7 Days	Fog Dmax	0.23 1.27	0.75 1.20	20	
.0	-	20.	Altor / Days	Dillax	1.27	1.20	20	
15		25	As is apparent from the invention had an excellent	e results shown in Tagreen shelf life. EXAMPLE	_	rial F of the present	25	
25		25	Thermally developable light sensitive material H was prepared in the same manner as sensitive material B except that a solution prepared by dissolving 10 mg of CeBr3·5H2O in 10 ml of methanol was added prior to the addition of N-bromoamide.					
10	1	30	Sensitive material B (en developed and tested as in	aployed for comparison	on) and sensitive mater	ial H were exposed, e 6.	30	
				Table	e 6	•		
35	:	35	Sensitive Material	Н	•	B (Comparison)	35	
	-		Sensitivity	230)	100		
	:		Fog	. 0	0.15	, 0.18		
10		40	Dmax	i	.20	1.41		
Ю	. ;	40	ΔD	0	.08	0.15	40	
	I		With respect to the degree excellent.					
15		45	Thermally developable sensitive material H in Exainstead of CeBra-5H2O.	imple 6 except that 10	ial I was prepared in the major of Ce(CH ₂ COCH	COCH ₃) ₃ was added	45	
			The results obtained after	er processing and test	ing as in Example 3 are	e shown in Table 7.		
: 0		50		Table	: 7		50	
٠,٤		56	Sensitive Material	I		B (Comparison)		
:5		55	Sensitivity .	195	i	100	55	
			Fog		0.17	0.18		
			Dmax		.25	1.41		
		<i>5</i> 0	ΔD		.08		60	
				·	·	0.13		

EXAMPLE 8

Thermally developable light sensitive material J was prepared in the same manner as sensitive material B in Example 1 except that a solution of 0.1 g of (NH₄)₂Ce(NO₃)₆ in 15 ml of methanol was added before the addition of color toning agent (e) (phthalazone).

The results obtained after processing and testing as in Example 1 are shown in Table 8.

			Table 8		
10	Sensitive Materi	al	С	B (Comparison)	10
		Sensitivity	98	100	
	Fresh	Fog	0.18	0.18	
15		Dmax	1.35	1.41	15
		Sensitivity	103	120	
	35°C, 80%	Fog	0.45	0.80	
20	After 7 Days	Dmax	1.30	1.33	20
25	high humidity conditions Furthermore, from Ta advantageous when amm WHAT WE CLAIM 1. A thermally devel	s can be preven ble 1 and Table lonium ceric nits IS: opable light-sen	ted by the use of a 8, it is apparent the ate was used in the	age under high temperature and mmonium ceric nitrate. at the fog preventing effect was formation of the silver laurate. h comprises in a support or in at	25
30	least one layer provided (a) an organic silver s (b) a photocatalyst what agent to form a silver in	alt; hich catalyses th	e reaction of an or	ganic silver salt with a reducing	30
35	(c) a reducing agent so tetrakisphenols; 3-pyrazy yamines; hydroxaminic a ropyridines, organic hy 1,4-dihydropyridines, ac dimethylaminodiphenyl least one layer of said lay	elected from sub olidones pyrazol cids; hydrazides drazone compo etoacetonitriles, and 4,4', 4''-die	ines and pyrazolone; indane-1, 3-dione ; indane-1, 3-dione unds, hydrazines, p-oxyphenylglycin ethyl amino tripher	otionally substituted bis, tris and es; phenylenediamines; hydroxis, amidoximes, substituted hydromino-9, 10-dihydroacridines, e, 4,4'-diaminodiphenyl, 4,4'æ nyl methane, said support or at e trivalent or tetravalent cerium	35
40	compound. 2. A material as clain following general formul Ce ₁ X _m .xH ₂ O (I) M ₀ Ce _p X _q .yH ₂ O (II)	ned in Claim 1, w la (I) or (II):	herein said cerium	compound is represented by the	40
45	and q each represents ar represents an integer of 3. A material as clair	i integer necess: 0 to 16 and M : ned in Claim 2,	ary to render the corepresents a cation wherein X is a nitre	ate ion, a hydroxide ion, a nitro	45
50	carbonate ion, a halogen carboxylic group. 4. A material as claim or an onium group.	ion, a perchlora ned in Claim 2 on	te ion, a phosphora 3, wherein M is a h	ion, an acetyl acetonate ion, a ate ion or a long chain aliphatic aydrogen ion, an alkali metal ion	50
55	5. A material as clai Ce(OH) ₃ , Ce(OH) ₄ , Ce(Ce(NO ₃) ₃ .6H ₂ O, Ce(NO ₃) (x = 0 and/or 3), Ko	D2, Ce2O3, Li8C 3)3.5H2O, Ce(N Ce(NO3)4.H2O.	eO6, Na2CeO3, KC O3)3.4H2O, Ce(NC K2Ce(NO3)3. K2C	om compound is selected from eO2, K2CeO3, CeN, Ce(NO3)3, O3)4.5H2O, CeOH(NO3)3.xH2O Ce(NO3)6, RbCe(NO3)6. H2O,	55
60	(CH ₃ COCHCOCH ₃) ₃ Ce CeCl ₃ , 7H ₂ O, Ce ₂ (SO ₄)	NH4)2Ce(NO3)5. , (NH4)2Ce(SO4 5.8H2O, Ce(SO4 Se(C104)3.6H2O	xH_2O (x = 0 an A_2O , (x = 0, 1) A_2XH_2O (x = 0, 2) A_2XH_2O (x = 0, 2) A_2XH_2O (x = 0, 2)	3.H ₂ O ₂ (NH ₄) ₂ Ce (NO ₃) ₆ , ad/or 4), Ce(CH ₃ COO) ₃ .H ₂ O ₂ and/or 8), Ce ₂ (CO ₃) ₃ .8H ₂ O ₃ , 4, 5, 8, 9 and/or 12), CeBr ₃ , sCOO) ₃ , Ce(C ₂₂ H ₄₅ COO) ₃ and	60

-	27	1,543,266	27
		7. A material as claimed in Claim 6, wherein the cerium complex salt is selected from $Ce(Dip)_2(NO_3)_3xH_2O$ (where Dip is 2,2'- bipyridyl and $x = 0$ to 16), $Ce(Dip)_2Br_3$,	
	5	Ce(Phen):(NO3)3 (where Phen is phenanthroline), Ce(Phen):(SCN)3,	5
1	10	Ce(Phtha)Br (where Phtha is phthalocyanine), Ce(Uro) ₂ (SCN) ₃ .8H ₂ O (where Uro is urotropin), Na ₃ [Ce(DP) ₃] (where DP is diphenic acid), Na[Ce(Naphth) ₂] (where Naphth is naphthalic acid) and NH ₄ [Ce(OX) ₂] x H ₂ O (where OX is oxalic acid and $x = 0$ to 16). 8. A material as claimed in any preceding Claim, wherein 5×10^{-1} to 1×10^{-5} mole of	10
1	15	component (b) is present per mole of organic silver salt (a). 9. A material as claimed in Claim 8, wherein 10 ⁻¹ to 10 ⁻⁴ mole of component (b) is present per mole of organic silver salt (a). 10. A material as claimed in any preceding claim, wherein said reducing agent is a 2,4-dialkyl substituted o-bisphenol or a 2,6-dialkyl substituted p-bisphenol, or mixtures thereof.	15
:	20	 A material as claimed in Claim 10, wherein said reducing agent is represented by the general formulae I or II shown and defined hereinbefore. A material as claimed in any preceding claim, wherein said photocatalyst is a light-sensitive silver halide. 	20
;	25	13. A thermally developable light-sensitive material, substantially as hereinbefore described with reference to material A, C, D, E, F, H, I or J of the foregoing Examples. 14. An image obtained by imagewise exposure and thermal development of a material as claimed in any preceding claim. 15. A method of manufacturing a thermally developable light-sensitive material as	25
	30	claimed in any preceding claim, which comprises incorporating component (d) into the thermally developable light-sensitive material by adding it to the reaction system or a reactant solution for formation of the organic silver salt and/or the light-sensitive silver halide before or during the formation thereof. 16. A method as claimed in claim 15, wherein component (d) is added to the reaction system by mixing a solution or a dispersion prepared by adding component (d) to a solution of	30
:	35	a silver salt-forming organic compound with an aqueous solution of a water soluble silver salt or a silver complex salt. 17. A method as claimed in Claim 15, wherein component (d) is added to the reaction system by mixing solutions consisting of a solution or dispersion of component (d), an aqueous solution of a silver salt or a silver complex salt and a solution or a dispersion of a	35
,	40	silver salt-forming organic compound. 18. A method as claimed in Claim 15, wherein component (d) is added by mixing a solution or a dispersion of a silver salt-forming organic compound with a mixed solution or a dispersion prepared by adding component (d) to a solution of a silver salt or a silver complex salt.	40
4	45	19. A method as claimed in Claim 15, wherein component (d) is added to a reactant solution for producing the light sensitive silver halide. 20. A method as claimed in Claim 15, wherein component (d) is added to the reaction system for preparing the light sensitive silver halide in the course of the reaction	45
	50	21. A method as claimed in Claim 15, wherein component (d) is added to the reaction system by adding said component (d) to one of the reactant solutions prepared for the formation of the organic silver salt and the silver halide, before or during the formation thereof.	50
;	55	22. A method as claimed in Claim 15, wherein component (d) is incorporated into the thermally developable light sensitive material by using the light sensitive silver halide produced by employing component (d) as a light sensitive silver halide-forming component. 23. A method of manufacturing a thermally developable light sensitive material, substantially as hereinbefore described with reference to material A, C, D, E, F, H, I or J of the foregoing Examples.	55
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